In-Situ High Temperature Characterization of La-Cr-O Thin Films by XRD, Raman, and TEM Nina Orlovskaya¹, David Steinmetz², Sergey Yarmolenko³, Jag Sankar³ ¹Michigan Technological University, MI; ²Drexel University PA; ³North Carolina A&T State University, NC

Introduction Catalytically active self-organized nano structured LaCrO₃ thin film is a prospective material for perovskite related membrane

reactors for synthesis of the syngas (CO+H₂) and for the high purity oxygen separation by selective diffusion. It also can be used as a protective coating against oxidation and corrosion of metallic interconnect for lower लं temperature SOFCs. For La-Cr-O based films deposited by magnetron sputtering, the films are typically amorphous because of unheated substrates. The films can be transformed to the required LaCrO₃ orthorhombic perovskite structure by additional annealing. In this work results of high temperature XRD, micro-Raman and TEM study of the structural evolution of La-Cr-O \rightarrow LaCrO₄ \rightarrow LaCrO₃ thin films are reported. A structural analysis of the film development as a function of temperature and environment is presented. The unique film structure is detected.



TEM of La-Cr-O Amorphous Thin Films







A La-Cr-O sample after heating at 760°C for ~1 hour in the microscope column

XRD Analysis of La-Cr-O Thin Film

In situ XRD was performed to study the structural evolution of the RF deposited La-Cr-O thin film during the heating in air. First, local ordering of Xamorphous film occurs via rav nucleation and subsequent growth that leads to a formation of medium range and short range ordered clusters. Such locally ordered phase has no characteristics of a crystalline phase such as visible peaks or diffraction in XRD or SAED patterns. spots Further heating initiates long range ordering of the monoclinic monazite type $LaCrO_4$ and La_2CrO_6 phases following by the formation of LaCrO₃ orthorhombic perovskite. Therefore, the thin film with a nanoporous self organized microstructure is formed as **60** a result of the two consecutive phase transitions by heat induced processes from the amorphous La-Cr-O state.

structural Local inhomogeneities X-ray amorphous La-Cr-O as deposited film; Short-range to medium-range ordered clusters with no characteristics of crystalline

phase. **Bright field image**







Chemical composition of LaCrO₃ grains and intergranular phases



TEM of LaCrO₃ Perovskite Thin Films, 800°C, 1 h, in air

Bright field TEM micrographs of LaCrO₃ perovskite thin film

clusters with a size of 1-2nm. •The LaCrO₃ orthorhombic to rhombohedral phase transition at 230°C has been demonstrated by in-situ micro-Raman spectroscopy.

 While annealing of the La-Cr-O thin films in air leads to formation of two consecutive phase transitions with a final orthorhombic LaCrO₃ perovskite phase, the annealing of La-Cr-O in vacuum in the TEM column leads to formation of orthorhombic LaCrO₃ structure directly at 750-800°C without any intermediate phases.

The work was supported by the National Science Foundation through grant # DMR-0201770 and 0502765. TEM work at UIC was supported by Army Nanoscience and Nanomaterials Center for NCA&TSU.



Raman Spectra during Heating of La-Cr-O and LaCrO₃ Thin Films

The LaCrO₃ thin film 300°C Rhombohedral 🔔 245°C Rhombohedral 230°C Rhombohedral Orthorhombic What we are and a second second second **Orthorhombic** RT 700 400 Raman Shift, cm⁻¹

In situ micro-Raman spectroscopy was used to study the vibrational properties La-Cr-O and LaCrO films. thin La-Cr-O to Both (La_2CrO_6) LaCrO_₄ phase transition at 505-515°C and LaCrO₃ film thin orthorhombic to rhombohedral phase transition at 230°C were demonstrated. Bands belonging to LaCrO₄ and La₂CrO₆ phases have also been detected during 1000 ^{the} heating of orthorhombic LaCrO₃ at 100°C in air.

Summary

 As a result of annealing at different temperatures, different film structures have been formed. The "asdeposited" La-Cr-O thin film was found to be X-ray amorphous with no visible spots in electron diffraction pattern, but after annealing in air, the film transforms first to a mixture of LaCrO₄ monazite type monoclinic phase and La₂CrO₆ phase at 600°C and further to the orthorhombic LaCrO₃ perovskite phase at 700-800°C

 While no electron diffraction spots can be seen in SAED pattern for La-Cr-O thin film, however its structure consists of short- to medium-range

Acknowledgments